Rational design of forest-like nickel sulfide hierarchical architectures with ultrahigh areal capacity as a binder-free cathode material for hybrid supercapacitors†

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**Fig. S1** FE-SEM images of pristine Ni foam, showing its porous conductive frames with smooth surface.
Fig. S2 (a) XRD patterns of NiS-based samples synthesized under different time intervals [i] 1 h, ii) 2 h, iii) 3 h and iv) 5 h], (b) HR-Raman, and (c–e) XPS survey scan spectrum, high-resolution Ni 2p and S 2p XPS spectra, respectively, of forest-like NiS NTs/Ni foam sample under the optimal growth condition of 85 ºC for 3 h.
Section 1: Structural, morphological and electrochemical properties of NiS on Ni foam without using the nickel salt in the growth solution:

Fig. S3a-c shows the low and high-magnification FE-SEM images of the nanostructured NiS on Ni foam, which was developed without Ni salt (Ni(NO$_3$)$_2$·6H$_2$O source) in the growth solution. Interestingly, NiS nanoparticles were observed on the Ni foam with a mass loading of 0.9 mg/cm$^2$ at the reaction temperature of 85 ºC for 3 h. This indicates that, forest-like NiS NTs on Ni foam were not formed without the addition of nickel salt in the growth solution. The structural and electrochemical properties of the corresponding sample was also examined. From the EDX (taken from FE-SEM equipment) and XRD results (Fig. S3d-e), it is evident that the prepared sample (without the addition of nickel salt) composed of Ni and S elements has pure NiS phase without any impurities. The XRD pattern of NiS/Ni foam showed low intense peaks, which may be due to the less amount material deposited on the spectrum. Furthermore, when tested the electrochemical properties in 1 M KOH solution, the NiS nanoparticles coated Ni foam exhibited a battery-type redox behavior, confirmed from the CV and GCD curves (Fig. S3f-g and Fig. S4a-b), which is similar to the forest-like NiS NTs electrode behavior. However, NiS nanoparticles coated Ni foam sample exhibited relatively low electrochemical performance compared to the forest-like NiS NTs/Ni foam electrode, as shown in Fig. S4a-b. The obtained results indicate that the inclusion of nickel salt in growth solution help to increase the nucleation and precipitation rate to form the hierarchically designed forest-like NiS NTs for the enhancement of energy storage performance.
Fig. S3. Physical and electrochemical properties of NiS nanoparticles coated Ni foam, which was prepared without addition of nickel salt in the growth solution. (a-c) low- and high-magnification FE-SEM images of NiS nanoparticles, (d-e) EDX and XRD pattern of the same sample. (f-h) CV curves, GCD curves and calculated areal capacity values of NiS nanoparticles coated Ni foam electrode, respectively.
Fig. S4. Comparative electrochemical properties of NiS nanoparticles and forest-like NiS NTs, which were prepared with and without inclusion of nickel salt in the growth solution. (a) CV curves (b) GCD curves and calculated capacity values of the both samples. This results indicate that the sample prepared with an inclusion of nickel salt (i.e., forest-like NiS NTs) ensued superior capacity values than the sample synthesized without addition of nickel salt in the growth solution.

Section 2: Effect of growth temperature on the morphological and electrochemical properties of NiS nanostructures on Ni foam: The effect of growth time on the structural and electrochemical properties of NiS on Ni foam were carried out under different temperatures of 50-115 °C with a constant growth time of 3 h. At the low growth temperature (50 °C), as shown in FE-SEM images of Fig. S5a, NiS with nanosheet like morphology was started to grow on Ni foam substrate. This means that the growth temperature is not enough to form the vertically aligned forest-like nanoarchitectures. With increasing the growth temperature to 85 °C, the forest-like NiS NTs were uniformly distributed on Ni foam due to the increased nucleation and growth rate of the added reactants (see FE-SEM images of Fig. 2). Further increasing the growth temperature to 115 °C (Fig. S5b), NiS nanostructures were densely integrated on Ni foam in the form of lumps with high mass loading. Also, several cracks were observed due to the extreme growth rate and
precipitation of added reactants. This kind of cracks may not useful for improving the capacity and rate capability of the prepared samples.

![FE SEM images of NiS nanostructures](image)

**Fig. S5.** FE SEM images of NiS nanostructures prepared at the growth temperatures of (a) 50 °C and (b) 115 °C.

The electrochemical properties of the prepared samples under different temperatures were included in Fig. S6. The comparative CV curves (measured at a scan rate of 10 mV/s), shown in Fig. S6a displayed the dynamic redox peaks, indicating the battery-type mechanism of NiS-based samples. Compared to other samples, the forest-like NiS NTs synthesized at 85 °C exhibited higher redox current and large enclosed CV area, revealing the high capacity contribution of the material. To estimate the capacity of the prepared samples, the GCD curves (Fig. S6b) also measured as a function of synthesis temperature. As shown in the comparative GCD curves (measured at a constant current density of 4 mA/cm²), the sample synthesized at high temperature (115 °C) demonstrated uneven charge-discharge times, where the material showed high charge time and small discharge time, which indicates the low columbic efficiency of the prepared sample and this could be due to the surface cracks and over mass loading of the material. On the other hand, as
shown in discharge curves of the prepared electrodes, the NiS synthesized at 85 °C demonstrated high discharge time compared to the other growth temperature samples. The calculated discharge capacities of these samples were plotted in Fig. S6c, which showed the areal capacities of 287.37, 752.71 and 386.88 μAh/cm² for the NiS nanostructures prepared at various growth temperatures of 50, 85, and 115 °C, respectively. Thus, we have chosen 85 °C and 3 h were the optimal growth conditions in the development of forest-like NiS NTs as a high capacity cathode material for the hybrid supercapacitors. The overall electrochemical properties, including CV at various scan rates, GCD at different current densities and calculated capacity plots, of NiS samples developed at 50 and 115 °C, were presented in Fig. S7.
Fig. S6. Comparative electrochemical properties of NiS nanostructures prepared under various growth temperatures.
Fig. S7. CV curves, GCD curves and calculated areal capacity values of the NiS-based samples synthesized at various growth temperatures of (a) 50 °C and (b) 115 °C, respectively.
**Fig. S8.** Electrochemical performance of NiS-based sampled deposited under different growth times of (a-b) 1 h, (c-d) 2 h and (e-f) 5 h, respectively with a constant growth temperature of 85 °C.
**Fig. S9** FE-SEM images of the forest-like NiS NTs/Ni foam after cycling test in three-electrode system.

**Fig. S10** (a) CV (b) GCD curves of PAC/Ni foam electrode in 1 M KOH solution.
Table S1. Comparative electrochemical properties of previously reported metal sulfide/selenide based nanostructures with forest-like NiS NTs/Ni foam electrode.

<table>
<thead>
<tr>
<th>Electroactive material</th>
<th>Current collector</th>
<th>Electrolyte</th>
<th>Test condition (mA/cm²)</th>
<th>Area (cm²)</th>
<th>Areal capacity (µAh/cm²)</th>
<th>Ref.</th>
</tr>
</thead>
<tbody>
<tr>
<td>Ni₃S₂ nanoparticles</td>
<td>Carbon fiber paper</td>
<td>2 M KOH</td>
<td>2</td>
<td>1</td>
<td>119.44</td>
<td>S1</td>
</tr>
<tr>
<td>NiSe microspheres</td>
<td>Ni foam</td>
<td>2 M KOH</td>
<td>3</td>
<td>0.6</td>
<td>1250</td>
<td>S2</td>
</tr>
<tr>
<td>Ni₃S₂ nanosheets</td>
<td>Ni foam</td>
<td>1 M KOH</td>
<td>1</td>
<td>1</td>
<td>154.16</td>
<td>S3</td>
</tr>
<tr>
<td>NiS box-in-box</td>
<td>Ni foam</td>
<td>3 M KOH</td>
<td>1</td>
<td>1</td>
<td>63.8</td>
<td>S4</td>
</tr>
<tr>
<td>Ni₃S₂@MWCNTs composite</td>
<td>Ni foam</td>
<td>2 M KOH</td>
<td>1.2</td>
<td>1</td>
<td>191.6</td>
<td>S5</td>
</tr>
<tr>
<td>NiSe nanowires</td>
<td>Ni foam</td>
<td>2 M KOH</td>
<td>5</td>
<td>1</td>
<td>700.1</td>
<td>S6</td>
</tr>
<tr>
<td>NiS nanoframes</td>
<td>Ni foam</td>
<td>6 M KOH</td>
<td>1</td>
<td>1</td>
<td>279.16</td>
<td>S7</td>
</tr>
<tr>
<td>NiS hollow spheres</td>
<td>Ni foam</td>
<td>2 M KOH</td>
<td>4.08</td>
<td>1</td>
<td>147.3</td>
<td>S8</td>
</tr>
<tr>
<td>CoS hollow tubes</td>
<td>Ni foam</td>
<td>6 M KOH</td>
<td>5</td>
<td>1.13</td>
<td>472.2</td>
<td>S9</td>
</tr>
<tr>
<td>CuS nanoneddles@CNT</td>
<td>Ni foam</td>
<td>2 M KOH</td>
<td>2.9</td>
<td>1</td>
<td>40.7</td>
<td>S10</td>
</tr>
<tr>
<td>NiS nanostructures</td>
<td>Graphene-Cotton</td>
<td>6 M KOH</td>
<td>0.5</td>
<td>1</td>
<td>172.1</td>
<td>S11</td>
</tr>
<tr>
<td>Forest-like NiS NTs</td>
<td>Ni foam</td>
<td>1 M KOH</td>
<td>4</td>
<td>1</td>
<td>752.71</td>
<td>This work</td>
</tr>
</tbody>
</table>

References.